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INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)		Applicant: Tsuyoshi NAKAMURA, et al.				
		Filing Date: July 11, 2001		Group: 1756		
U.S. PATENT DOCUMENTS						
Examiner Initial		Document Number	Date	Name	Class	Sub-Class
<i>YCT</i>		5,234,793	08/10/1993	Sebald et al.		
<i>YCT</i>		5,234,794	08/10/1993	Sebald et al.		
<i>YCT</i>		5,250,375	10/05/1993	Sebald et al.		
<i>YCT</i>		6,110,637	08/29/2000	Sezi et al.		
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SEP 10 2001						
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FOREIGN PATENT DOCUMENTS						
		Document	Date	Country	Class	Sub-class
<i>yct</i>		11-212265	08/06/1999	Japan		Abstract
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)						
<i>yct</i>	Sebald et al., <i>Chemical Amplification of Resist Lines (CARL)</i> , Microelectronic Engineering, pp. 531-534					
EXAMINER: <i>Yoshi C. Shetrone</i>		DATE CONSIDERED: <i>4-11-03</i>				